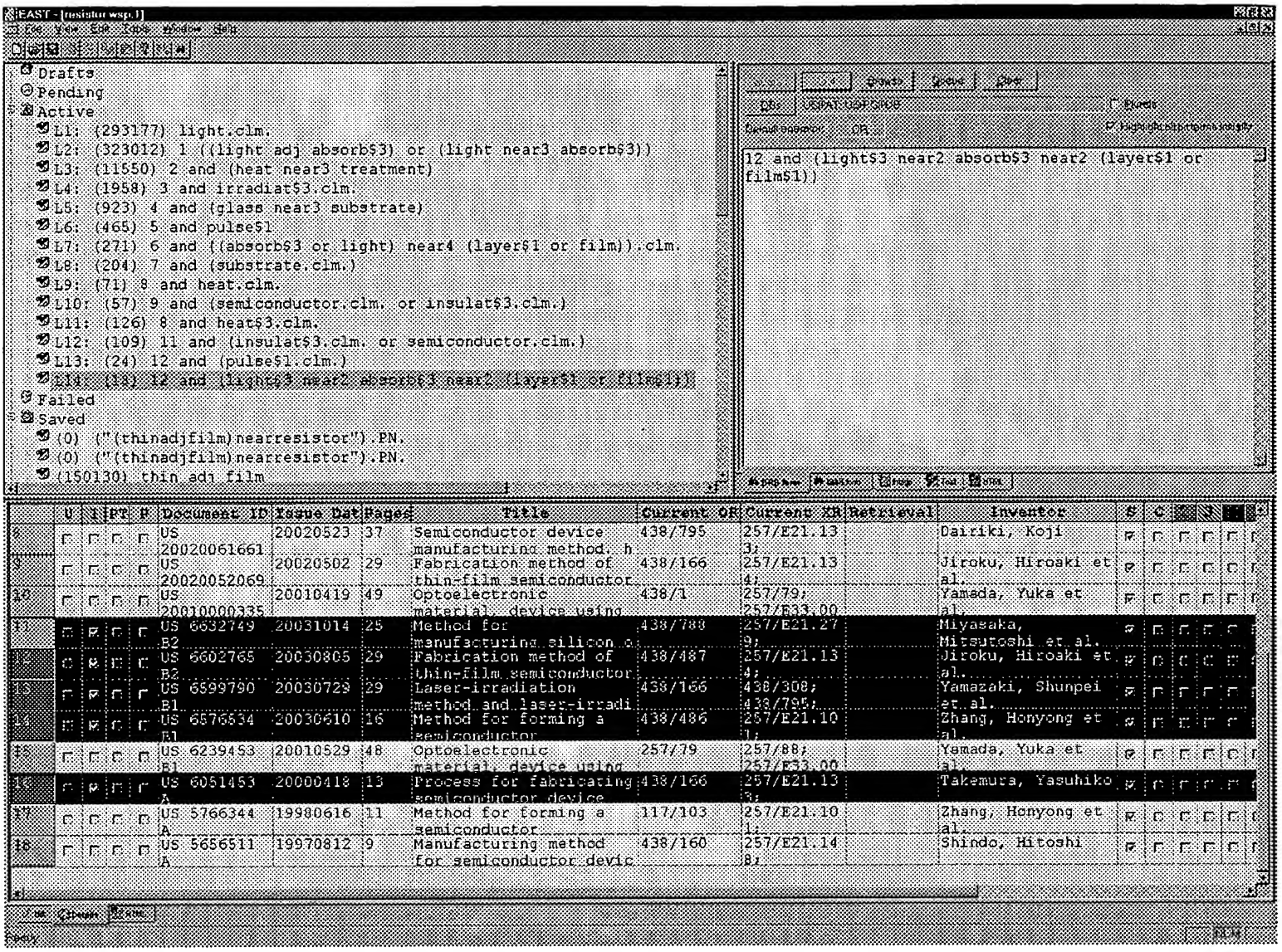

	U	I	PT	P	Document ID	Issue Dat	Pages	Title	Current OR	Current XR	Retrieval	Inventor	#
6					US 20020061661	20020523	37	Semiconductor device manufacturing method, h	438/795	257/E21.133;		Dairiki, Koji	
9					US 20020052069	20020502	29	Fabrication method of thin-film semiconductor	438/166	257/E21.134;		Jiroku, Hiroaki et al.	
10					US 20010000335	20010419	49	Optoelectronic material, device using	438/1	257/79; 257/E33.00		Yamada, Yuka et al.	
11					US 6632749 B2	20031014	25	Method for manufacturing silicon o	438/788	257/E21.279;		Miyasaka, Mitsutoshi et al.	
12					US 6602765 B2	20030805	29	Fabrication method of thin-film semiconductor	438/487	257/E21.134;		Jiroku, Hiroaki et al.	
13					US 6599790 B1	20030729	29	Laser-irradiation method and laser-irradi	438/166	438/308; 438/795;		Yamazaki, Shunpei et al.	
14					US 6576534 B1	20030610	16	Method for forming a semiconductor	438/486	257/E21.101;		Zhang, Hongyong et al.	
15					US 6239453 B1	20010529	48	Optoelectronic material, device using	257/79	257/88; 257/E33.00		Yamada, Yuka et al.	
16					US 6051453 A	20000418	13	Process for fabricating semiconductor device	438/166	257/E21.133;		Takemura, Yasuhiko	
17					US 5766344 A	19980616	11	Method for forming a semiconductor	117/103	257/E21.101;		Zhang, Hongyong et al.	
18					US 5656511 A	19970812	9	Manufacturing method for semiconductor devic	438/160	257/E21.148;		Shindo, Hitoshi	